Abstract

An apparatus for treating particle-shaped material has a process chamber for accommodating and treating the material. A base is composed of guide plates which are placed one above the other in different planes and overlap one another and between which slots are arranged, via which process air can be directed into the process chamber with an essentially horizontal component motion. It is proposed to provide a vertical—adjustment device which interacts with the guide plates and by means of which the distance between the guide plates and thus the height of the slots can be varied.